

REPORT

2nd Homework



Subject	Computational Microelectronics
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Due Date	2018/09/17 - 8AM

<Selection of the model>

I choose the distance of material that these are set to be 100nm with half silicon layer and half SiO₂ layer. Through calculating of the general Poisson equation, the analytic solution per area is below

$$C = \left(\frac{t_{ox}}{\epsilon_{ox}} + \frac{t_{si}}{\epsilon_{si}} \right)^{-1} = 5.175 \times 10^{-4} \text{ F/m}^2 \quad (= 517.503 \text{ } \mu\text{F/m}^2)$$

$$\epsilon_0 = 8.85 \times 10^{-12}$$

$$\epsilon_{ox} = 3.9 \times 8.85 \times 10^{-12}$$

$$\epsilon_{si} = 11.68 \times 8.85 \times 10^{-12}$$

$$t_{ox} = 50 \times 10^{-9} \text{ m}$$

$$t_{si} = 50 \times 10^{-9} \text{ m}$$

<MATLAB Simulation>

The discrete number is 1001-point and the electrostatic potential boundaries of $\phi(1)$ and $\phi(1001)$ are selected by 1 and 0 respectively. The first layer is SiO₂. Through the derived discretization equation from the general Poisson equation, I can figure out the total charge per area by the law of coulomb.

$$Q = C \cdot V \quad (V = 1) = C$$

$$= \epsilon_{ox} * \frac{\phi(1) - \phi(2)}{\Delta x} \quad \text{or} \quad \epsilon_{si} * \frac{\phi((N+1)/2) - \phi((N+3)/2)}{\Delta x}$$

$$= \epsilon_{ox} * \frac{\phi((N-1)/2) - \phi((N+1)/2)}{\Delta x} \quad \text{or} \quad \epsilon_{si} * \frac{\phi(1000) - \phi(1001)}{\Delta x}$$

The capacitance per area is solution of the above equation. Since the boundary condition voltage is set by 1. Both the analytic solution and MATLAB simulation are almost same results that the capacitance is ' $5.1776 \times 10^{-4} \text{ F/m}^2 (= 517.50 \text{ } \mu\text{F/m}^2)$ '.

So I confirm that the analytic and the general Poisson equation are almost same and valid for calculating the unit area capacitance.

** The MATLAB code is shown in the next page.

```

1 - clc; clear all;
2
3 - E_0 = 8.85*10^(-12); % permittivity of vacuum state
4 - E_ox = 3.9 * E_0; % permittivity of silicon di-oxide
5 - E_si = 11.68 * E_0; % permittivity of silicon
6 - d = 100 * 10^(-9); % Total distance of tox and tsi junction
7 - N = 1001; % The number of digitation point
8 - delx = d/(N-1); % The digitization step (unit distance)
9
10 - k_si = (-E_si);
11 - k_ox = (-E_ox);
12
13 - A_V = zeros(N,N); % set the LSH vector using general poisson equation
14 - A_V(1,1) = 1;
15 - A_V(N,N) = 1;
16 - B = zeros(N,1); % set the RHS vector using Boundary condition
17 - B(1,1) = 1;
18 -
19 - for i = 2 : (N+1)/2
20 -     if i == (N+1)/2
21 -         A_V(i,i+1) = k_si;
22 -         A_V(i,i) = -(k_ox + k_si);
23 -         A_V(i,i-1) = k_ox;
24 -     else
25 -         A_V(i,i-1) = k_ox;
26 -         A_V(i,i) = (-2)*k_ox;
27 -         A_V(i,i+1) = k_ox;
28 -     end
29 - end
30 - for i = (N+1)/2+1 : N-1
31 -     A_V(i,i-1) = k_si;
32 -     A_V(i,i) = (-2)*k_si;
33 -     A_V(i,i+1) = k_si;
34 - end
35
36 - X = A_V\B; % Calculation for psi vector
37 - Q_ox_1 = E_ox*((X(1,1)-X(2,1))/delx);
38 - Q_ox_2 = E_ox*((X(500,1)-X(501,1))/delx);
39 - Q_si_1 = E_si*((X(501,1)-X(502,1))/delx);
40 - Q_si_2 = E_si*((X(N-1,1)-X(N,1))/delx);
41 - % Calculation of Discretization
42 - % that it is derived from the general poisson equation
43
44 - Analytic_sol = 1/(d/2*(1/E_ox + 1/E_si)); % Analytic solution for comparison

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